

LIST OF ABBREVIATIONS USED IN THE THESIS

DS	: Derivative Spectrophotometry
SD	: Standard deviation
σ	: Standard deviation of the reagent blank
D	: Density
RSD	: Relative standard deviation
Q _L	: Quantitation limit
D _L	: Detection limit
ETU	: Ethylene Thiourea
DFT	: Density functional theory
TG	: Thermogravimetry
DTA	: Differential Thermal Analysis
IR	: Infra Red
UV	: Ultra Violet
NMR	: Nuclear Magnetic Resonance
ESR	: Electron Spin Resonance
TCNE	: Tetracyanoethylene
VOIP	: Valence orbital ionization potential
ADME	: Absorption, distribution, metabolism and elimination
HIA	: Human intestinal absorption
BBB	: Blood-Brain Barrier
MM	: Molecular mechanics
SE	: Semi empirical calculations
HEMTDT	: (E)-4-(2-hydroxyphenyl) ethylideneamino)-6-methyl-3-thioxo-3, 4-dihydro-1, 2, 4-triazin-5(2H)-one
CBMTDT	: (E)-4-(2-chlorobenzylideneamino)-6- methyl-3-thioxo-3, 4-dihydro-1, 2, 4-triazin-5(2H)-one

MMTDT	: (E)-4-(4-methoxybenzylideneamino)-6-methyl-3-thioxo-3, 4-dihydro-1, 2, 4-triazin-5(2H)-one
DMSO	: Dimethyl sulfoxide
DMF	: Dimethyl formamide
V.P.I	: Vapor phase inhibitor
SAM	: Self-assembled monolayer
OCP	: Open Circuit Potential
EIS	: Electrochemical impedance spectroscopy
LPR	: Linear Polarization Resistance
B3LYP	: Becke 3 Lee-Yang-Parr
MBATD	: (E)-(4-(4-methoxybenzylideneamino)-4H-1, 2, 4-triazole-3, 5-diyl) dimethanol
IE	: Inhibition efficiency
PMMA	: Polymethylmethacrylate
MS	: Mild Steel
SCE	: Saturated calomel electrode
R_{ct}	: Charge transfer resistance
C_{dl}	: Double layer capacitance
i_{corr}	: Corrosion current density
K_{ads}	: Equilibrium constant of the adsorption process
E_{corr}	: Corrosion potential
β_a	: Anodic Tafel slope
β_c	: Cathodic Tafel slope
HOMO	: Highest Occupied Molecular Orbital
LUMO	: Lowest Unoccupied Molecular Orbital
EDAX	: Energy dispersive x-ray
SEM	: Scanning Electron microscopy

ΔS_{ads}^0	:	Entropy of Adsorption
ΔH_{ads}^0	:	Enthalpy of adsorption
ΔG_{ads}^0	:	Free energy of adsorption
E_{total}	:	The total energy
$E_{\text{rigid adsorption}}$:	Rigid adsorption energy
$E_{\text{deformation}}$:	Deformation energy
A	:	Electron affinity
I	:	Ionization potential
χ_{M}	:	The absolute electro negativity of metal
χ_{inh}	:	The absolute electro negativity of the inhibitor molecule
η_{M}	:	The absolute hardness of metal
η_{inh}	:	The absolute hardness of inhibitor molecules
ΔN	:	The number of electrons transferred
a.c	:	Alternating current
k	:	Equilibrium constant
R	:	Gas constant
T	:	Temperature
t	:	Time
f+	:	Site for nucleophilic attack
f-	:	Site for electrouleophilic attack